

REF	760-1	6×3mL	EXP	2026-10-29	LOT	487DAB3	更新日期：	2024-05
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		批号：487DAB3			
项目\仪器\试剂\方法	单位	均值 \ CV		Lab \ 点数	
(Al)铝					
OTHER Dedicated \ ICP-MS	mg/L	0.011	10.2%	<5	<100
(As)砷					
OTHER Dedicated \ ICP-MS	mg/L	0.002	10.2%	<5	<100
(Au)金					
OTHER Dedicated \ ICP-MS	µg/L	0.08	9.4%	<5	<100
(B)硼					
OTHER Dedicated \ ICP-MS	mg/L	0.086	10%	<5	<100
(Ba)钡					
OTHER Dedicated \ ICP-MS	mg/L	0.486	10%	<5	<100
(Br)溴					
OTHER Dedicated \ ICP-MS	mg/L	0.972	10%	<5	<100
(Ca)钙					
OTHER OTHER \ OTHER	mmol/L	0.431	8.1%	<5	<100
OTHER Dedicated \ ICP-MS	mmol/L	0.405	10%	<5	<100
(Cd)镉					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	µmol/L	0.003	6.6%	11	102
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	µg/L	0.362	6.6%	11	102
OTHER Dedicated \ ICP-MS	µmol/L	0.003	10.5%	<5	<100
OTHER Dedicated \ ICP-MS	µg/L	0.38	10.5%	<5	<100
(Co)钴					
OTHER Dedicated \ ICP-MS	µmol/L	0.004	13.6%	<5	<100
OTHER Dedicated \ ICP-MS	µg/L	0.22	13.6%	<5	<100
(Cr)铬					
OTHER Dedicated \ ICP-MS	µg/L	0.76	10.5%	<5	<100
(Cs)铯					
OTHER Dedicated \ ICP-MS	mg/L	0.003	10%	<5	<100
(Cu)铜					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	µmol/L	10.5	14.4%	22	327
OTHER Dedicated \ ICP-MS	µmol/L	10.5	10%	<5	<100
(Fe)铁					
OTHER Dedicated \ ICP-MS	µmol/L	6186	10%	<5	<100
(Hg)汞					
OTHER Dedicated \ ICP-MS	µmol/L	0.009	10.9%	<5	<100
(I)碘					
OTHER Dedicated \ ICP-MS	µg/L	27	10%	<5	<100
(K)钾					
OTHER Dedicated \ ICP-MS	mmol/L	30.5	10%	<5	<100
(Mg)镁					
OTHER OTHER \ OTHER	mmol/L	0.62	7.7%	<5	<100
OTHER Dedicated \ ICP-MS	mmol/L	0.666	10%	<5	<100
(Mn)锰					
OTHER Dedicated \ ICP-MS	µg/L	20.5	10.2%	<5	<100
(Mo)钼					
OTHER Dedicated \ ICP-MS	µg/L	1.08	10.2%	<5	<100
(Na)钠					
OTHER Dedicated \ ICP-MS	mmol/L	65.8	10%	<5	<100

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		批号：487DAB3			
项目\仪器\试剂\方法	单位	均值 \ CV		Lab \ 点数	
(Ni)镍					
OTHER Dedicated \ ICP-MS	μg/L	2.16	10.2%	<5	<100
(P)磷					
OTHER Dedicated \ ICP-MS	mmol/L	6.28	10%	<5	<100
(Pb)铅					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	0.09	15.5%	21	310
OTHER Dedicated \ ICP-MS	μmol/L	0.058	10%	<5	<100
(Rb)铷					
OTHER Dedicated \ ICP-MS	mg/L	1.62	10%	<5	<100
(S)硫					
OTHER Dedicated \ ICP-MS	mg/L	1080	10%	<5	<100
(Sb)锑					
OTHER Dedicated \ ICP-MS	mg/L	0.004	10.3%	<5	<100
(Se)硒					
OTHER Dedicated \ ICP-MS	μmol/L	0.096	10%	<5	<100
(Si)硅					
OTHER Dedicated \ ICP-MS	mg/L	0.54	10%	<5	<100
(Sn)锡					
OTHER Dedicated \ ICP-MS	μg/L	0.22	9.8%	<5	<100
(Sr)锶					
OTHER Dedicated \ ICP-MS	mg/L	0.045	10%	<5	<100
(Ti)铈					
OTHER Dedicated \ ICP-MS	μg/L	5.4	10%	<5	<100
(V)钒					
OTHER Dedicated \ ICP-MS	μg/L	0.32	10.1%	<5	<100
(Zn)锌					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	76	6.9%	22	327
OTHER Dedicated \ ICP-MS	μmol/L	74.4	10%	<5	<100

注：此报告所提供的数据均基于检测相同批号质控品的若干实验室的数据汇总统计而来，仅供学习、参考之用。因所用技术、仪器和试剂的不同，或因制造商检测方法的改变，均可导致实验室实际测得的数据偏离此报告所提供的数据。根据良好实验室规范的要求，实验室须遵循相关技术规范确立自己的均值和可接受范围。